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(12) **United States Design Patent**
Schwartz et al.

(10) **Patent No.:** **US D958,966 S**
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(54) **FACE MASK**
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(73) Assignee: **Desprez, LLC**, New London, NH (US)

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(**) Term: **15 Years**

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(Continued)

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(51) **LOC (13) Cl.** **29-02**

(52) **U.S. Cl.**
USPC **D24/110.1**; D29/108

(58) **Field of Classification Search**
USPC D24/110, 110.1-110.6; D29/108
CPC . A41D 13/11; A41D 13/1107; A41D 13/1115;
A41D 13/1123; A41D 13/113; A41D
13/1138; A41D 13/1146; A41D 13/1153;
A41D 13/1161; A41D 13/1169; A61M
16/06; A62B 18/00; A62B 18/02; A62B
18/025; A62B 23/00

See application file for complete search history.

Primary Examiner — Richard Kearney
Assistant Examiner — Michael Hoffman
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(57) **CLAIM**

The ornamental design for a face mask, as shown and described.

DESCRIPTION

FIG. 1 is a front, top and right side perspective view of a face mask showing our new design according to a first embodiment;

FIG. 2 is a front elevational view thereof;

FIG. 3 is a right elevational view thereof;

FIG. 4 is a rear elevational view thereof;

FIG. 5 is a top plan view thereof; and,

FIG. 6 is a bottom plan view thereof.

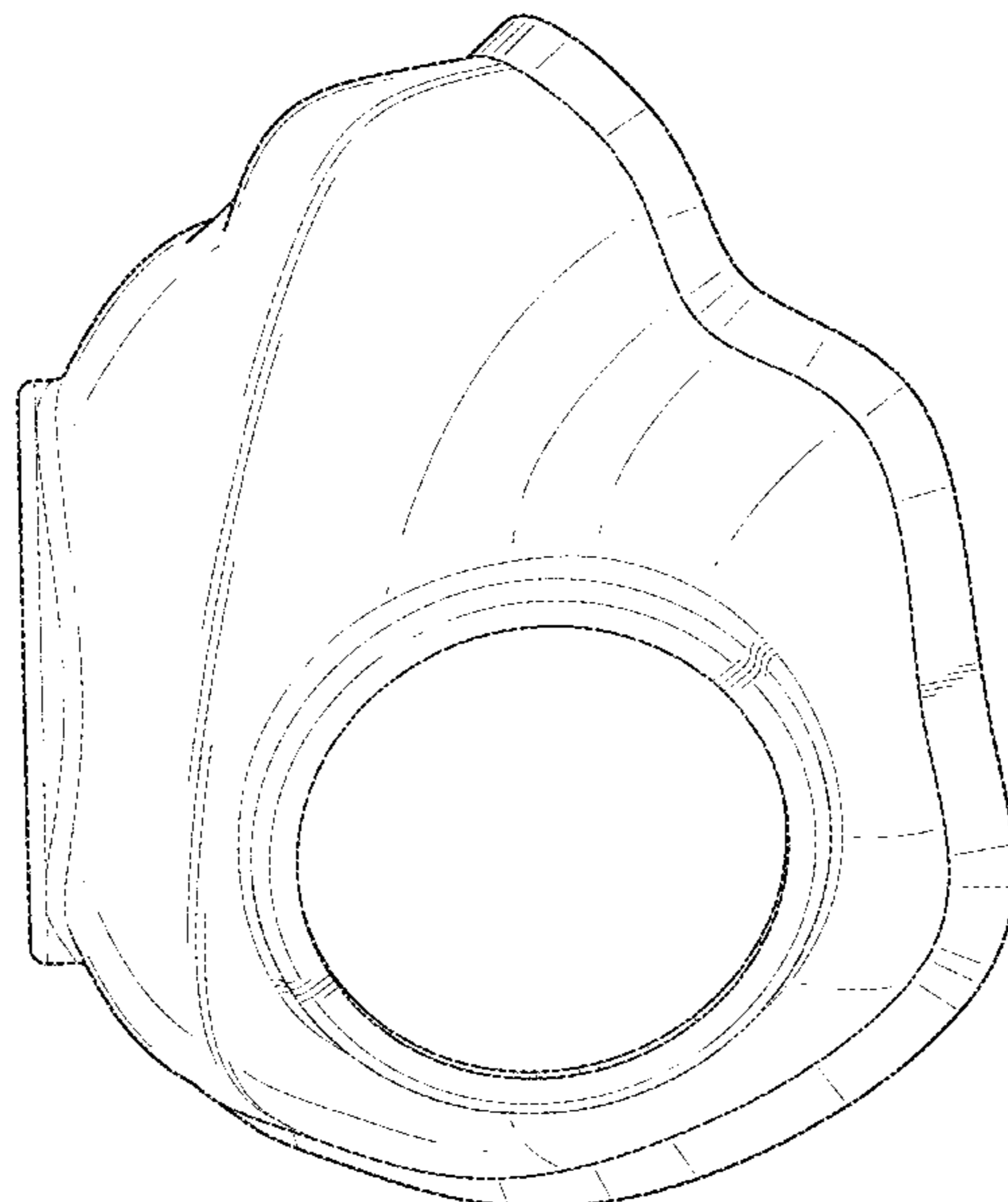
The broken lines in the drawings showing portions of the face mask are included for the purpose of illustrating environmental structure and form no part of the claimed design.

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1 Claim, 6 Drawing Sheets



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FIG. 1

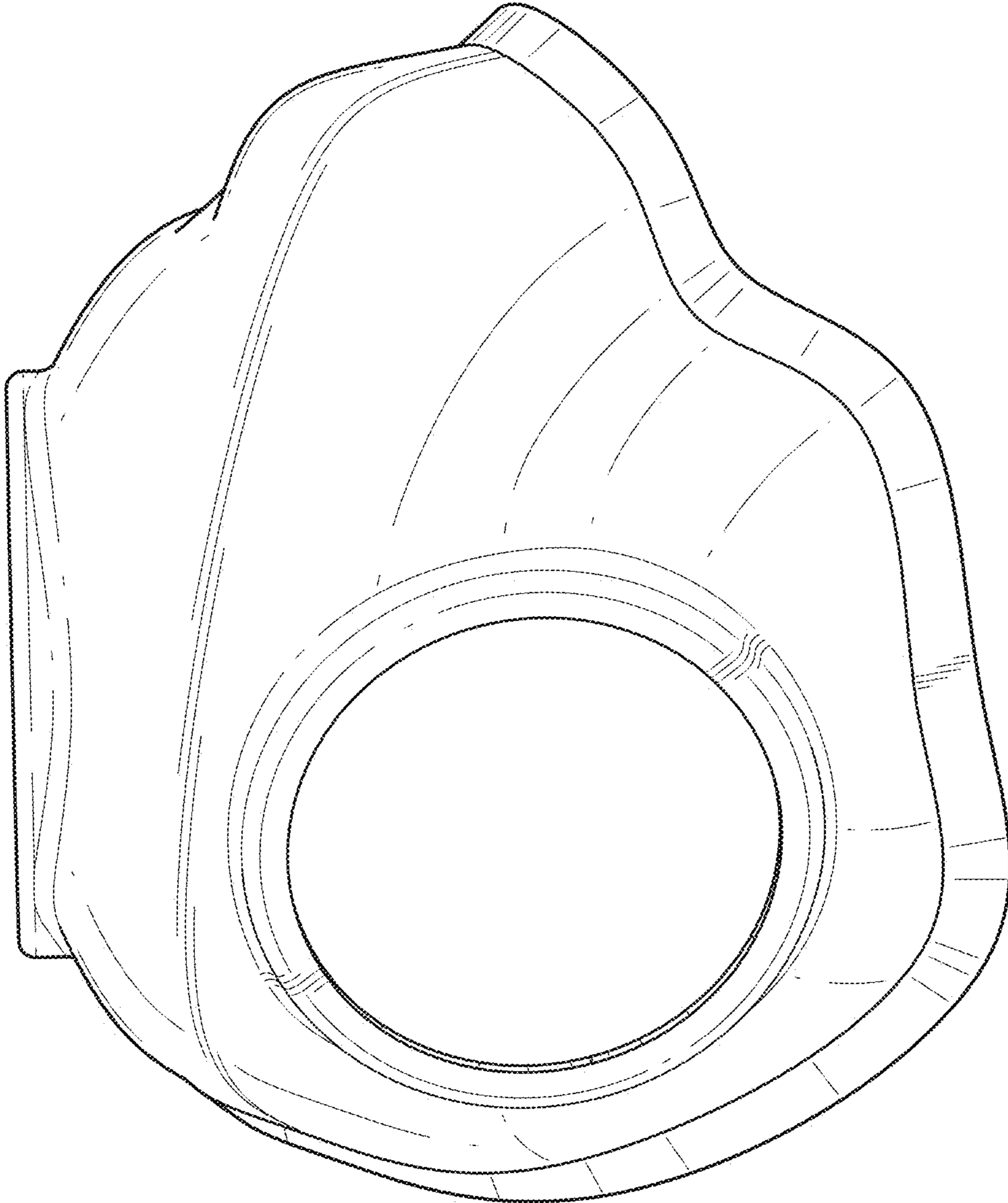


FIG. 2

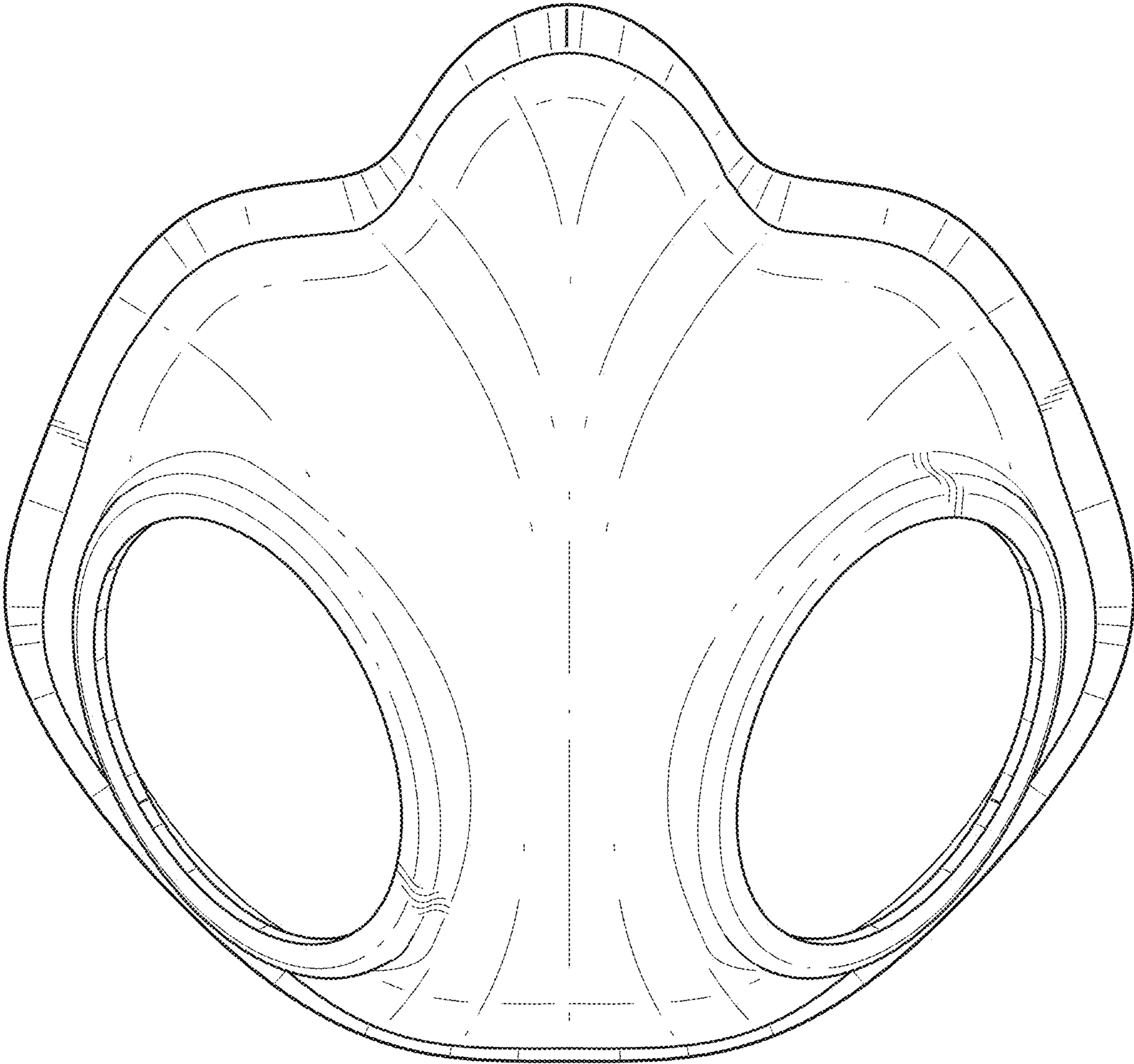


FIG. 3

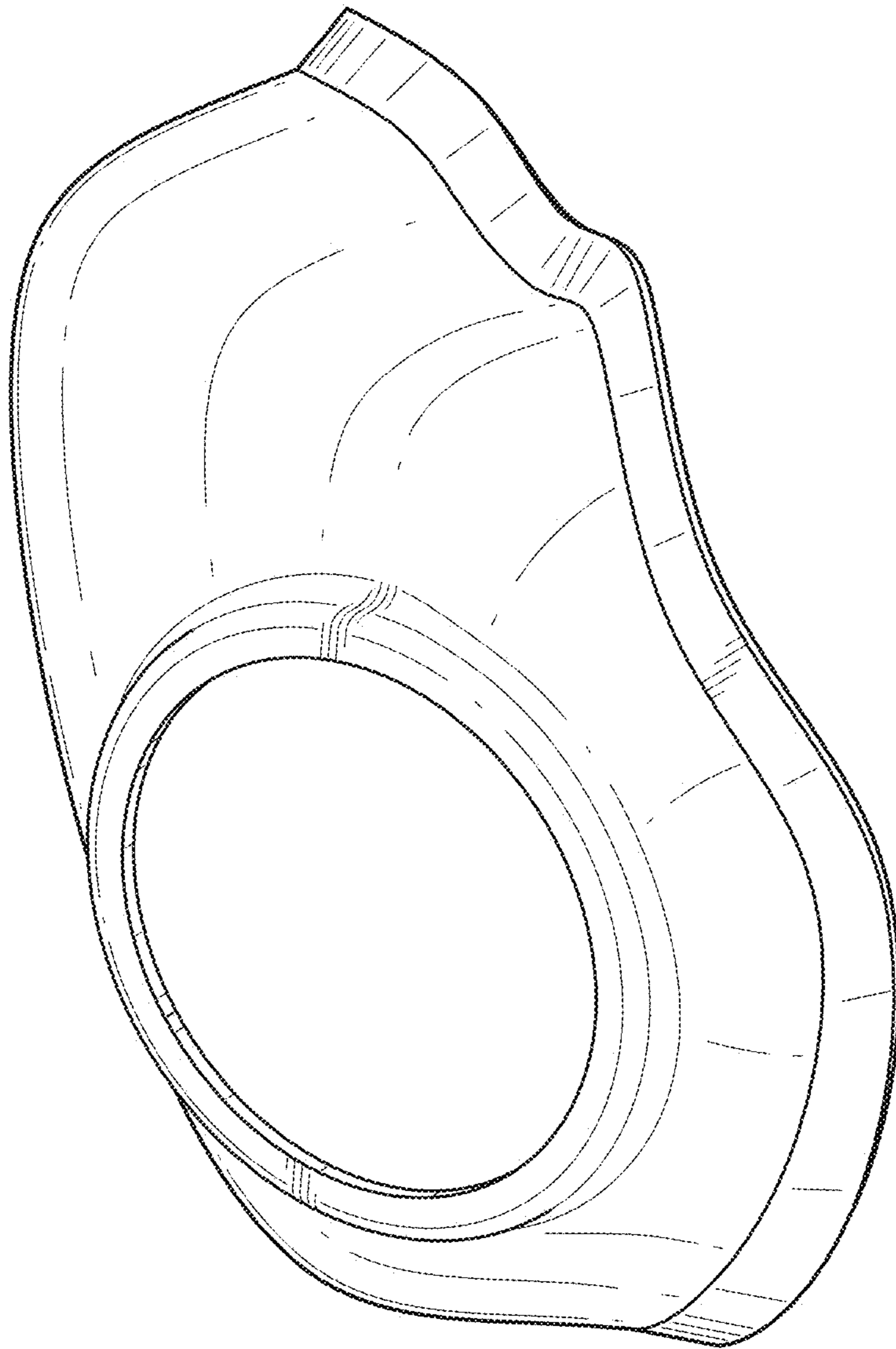


FIG. 4

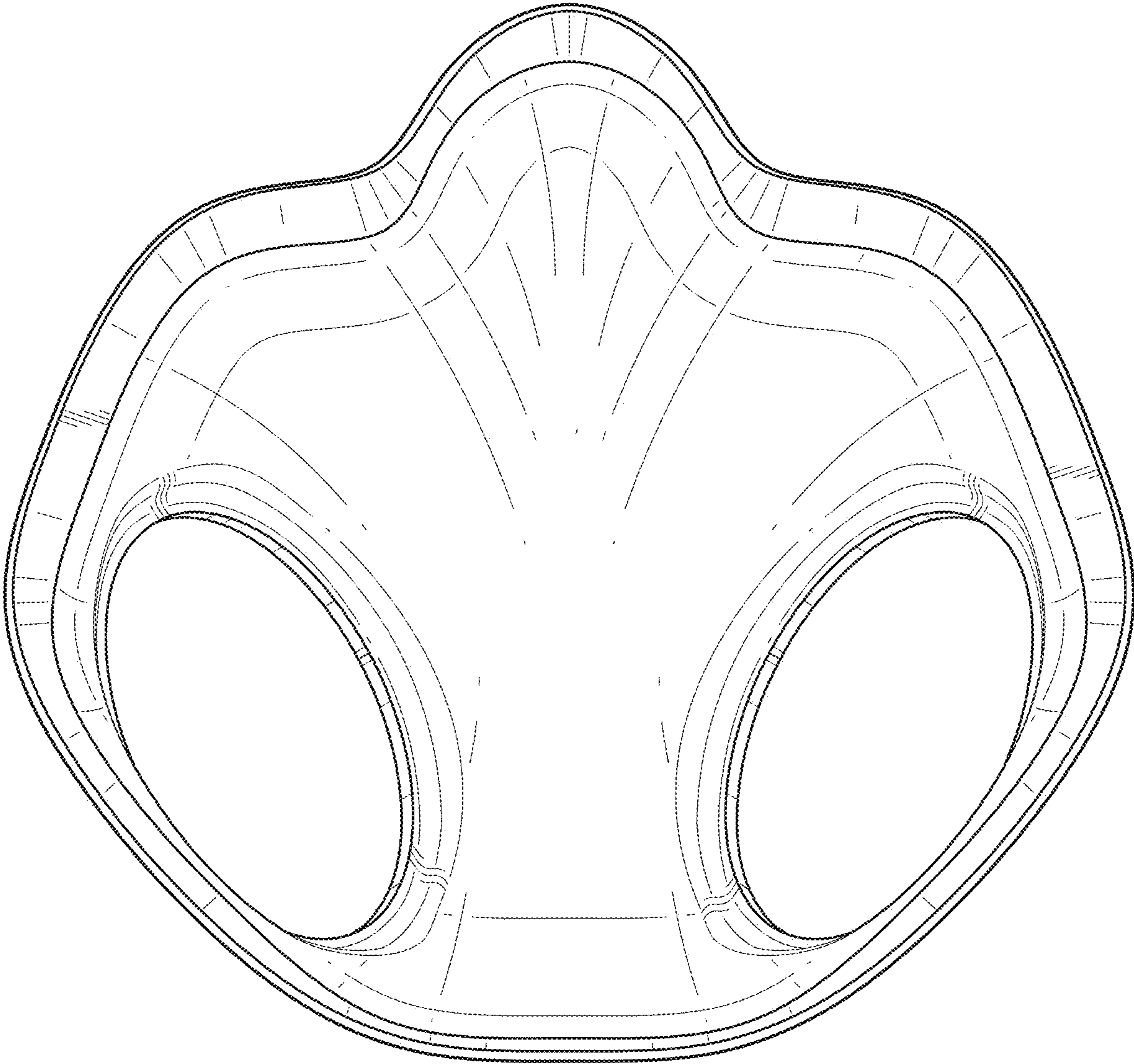


FIG. 5

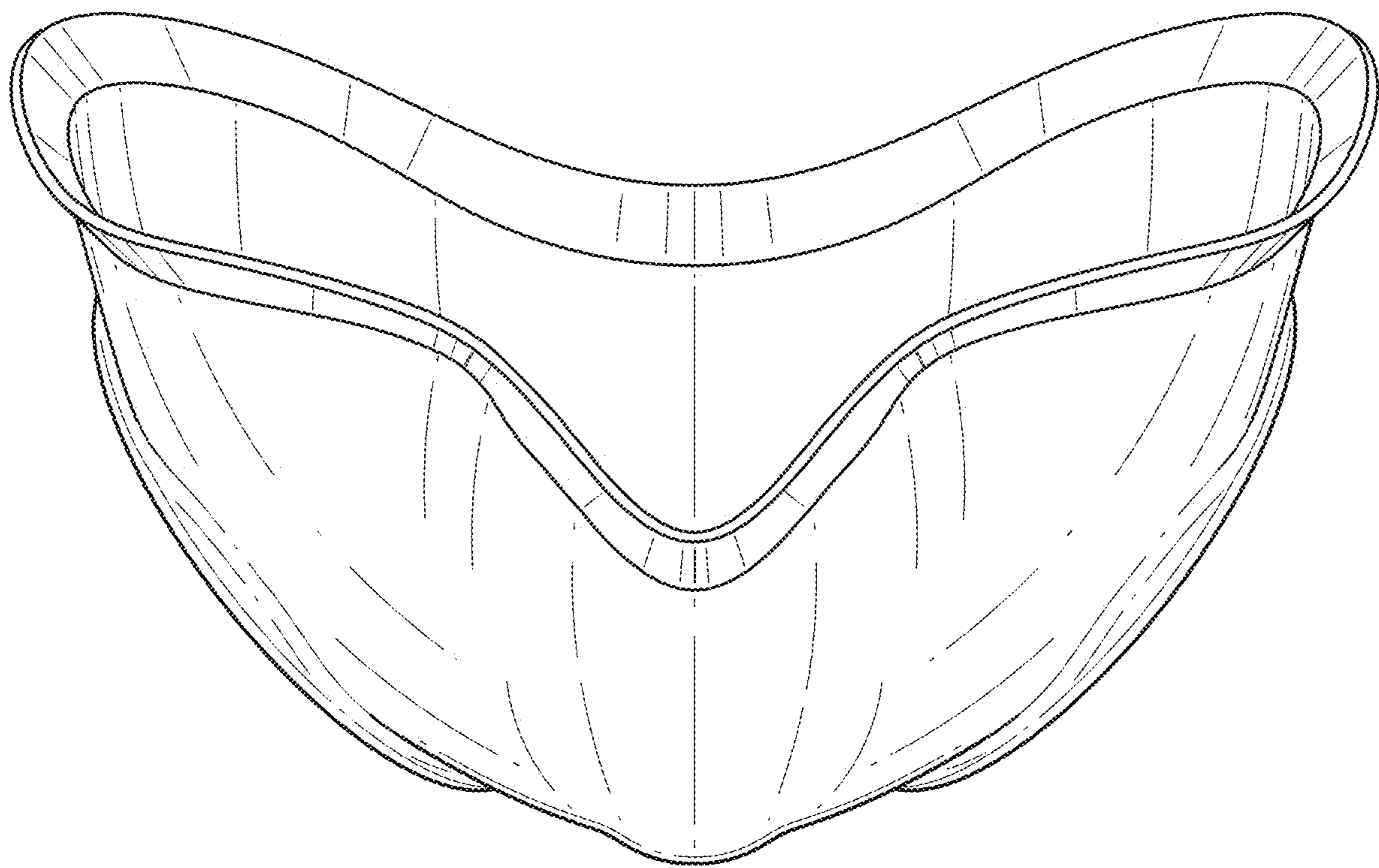


FIG. 6

